

| | Typ | L # | Hits | S arch T xt | DBs |
|----|-----|-----|------|--|---|
| 1 | BRS | L1 | 121 | (deposition or depositing or deposit or deposited) near20 trisilane | USPAT; US-PG PUB |
| 2 | BRS | L3 | 1 | 2 same (simultaneous or simultaneously) | USPAT; US-PG PUB |
| 3 | BRS | L2 | 18 | 1 same (germanium or ge) | USPAT; US-PG PUB |
| 4 | BRS | L4 | 27 | (deposition or depositing or deposit or deposited) near20 trisilane | EPO; JPO; DERWE NT; IBM_TD B |
| 5 | BRS | L5 | 5 | 4 and (germanium or ge) | EPO; JPO; DERWE NT; IBM_TD B |
| 6 | BRS | L6 | 4604 | (monocrystal or (single adj crystalline)) same (amorphous or polycrystalline or polysilicon) | USPAT; US-PG PUB |
| 7 | BRS | L7 | 1012 | 6 same (deposit or depositing or deposition) | USPAT; US-PG PUB |
| 8 | BRS | L8 | 3114 | (monocrystal or (single adj crystalline)) near20 (amorphous or polycrystalline or polysilicon) | USPAT; US-PG PUB |
| 9 | BRS | L9 | 250 | 8 near20 (deposit or depositing or deposition) | USPAT; US-PG PUB |
| 10 | BRS | L10 | 900 | (monocrystal or (single adj crystalline)) near2 (surfaces or surface) | USPAT; US-PG PUB |
| 11 | BRS | L11 | 5788 | (amorphous or polycrystalline or polysilicon) adj2 (surfaces or surface) | USPAT; US-PG PUB |
| 12 | BRS | L12 | 20 | 10 same 11 | USPAT; US-PG PUB |